



Amendment Under 37 C.F.R. § 1.116  
Group Art Unit 2879, Expedited Procedure

03500.014023

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

TAMAKI KOBAYASHI ET AL.

Application No.: 09/440,535

Filed: November 16, 1999

For: SUBSTRATE FOR ELECTRON  
SOURCE, ELECTRON SOURCE  
AND IMAGE FORMING APPARA-  
TUS, AND MANUFACTURING  
METHOD THEREOF

Examiner: A. Patel

Group Art Unit: 2879

November 3, 2003

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Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL REJECTION  
AND  
PETITION FOR EXTENSION OF TIME

Sir:

Applicants hereby petition to extend the time for responding to the Office

Action (Paper No. 17) of July 3, 2003 by one month, to and including November 3, 2003.

I hereby certify that this correspondence is being deposited with the  
United States Postal Service as first-class mail in an envelope  
addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria,  
VA 22313-1450 on November 3, 2003.

(Date of Deposit)

FRANK A. DeLUCIA, JR. (REG. #42,476)

(Name of Attorney for Applicant)

Signature

November 3, 2003

Date of Signature

11/10/2003 BABRAHA1 00000122 09440535

02 FC:1251

110.00 0P

A check in the amount of \$110.00 in payment of the issue fee is enclosed herewith. Please charge any deficiency in this fee, and credit any overpayment, to Deposit Account 06-1205.

In response to the Office Action, please amend the above-identified application as follows, pursuant to 37 C.F.R. § 1.116.

The claims are listed beginning at page 3. The Remarks begin at page 7.